



PATENT APPLICATION

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Satoshi INOUE et al.

Group Art Unit: 2812

Application No.: 10/748,206

Examiner: R. BOOTH

Filed: December 31, 2003

Docket No.: 040852.98

For: MANUFACTURING METHOD OF ACTIVE MATRIX SUBSTRATE , ACTIVE MATRIX SUBSTRATE AND LIQUID CRYSTAL DISPLAY DEVICE

RESPONSE TO QUAYLE ACTION

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In reply to the September 12, 2007 Quayle Action, reconsideration of the objection is respectfully requested in light of the following remarks.

Applicants appreciate the allowance of claims 55-68. The application is in condition for allowance for at least the reasons discussed below.

The Quayle Action objects to the application as lacking written consent of the assignees. All of the requisite information was properly submitted to, and accepted by, the Patent Office on December 31, 2003. Applicants' representative has confirmed that copies of the documents containing the requested information are scanned into the Patent Office's Image File Wrapper, as discussed below.

Applicants submitted written consent of the assignee to reissue on December 31, 2003, as reflected on page 4 of the Image File Wrapper document entitled "Oath or Declaration Filed." The assignee's ownership interest of the reissue application is of record.